

# Philippe De Rouffignac

## List of Publications by Year in descending order

Source: <https://exaly.com/author-pdf/10871552/publications.pdf>

Version: 2024-02-01

4

papers

312

citations

1937685

4

h-index

2272923

4

g-index

4

all docs

4

docs citations

4

times ranked

521

citing authors

#	ARTICLE	IF	CITATIONS
1	Atomic Layer Deposition of Y <sub>2</sub> O <sub>3</sub> Thin Films from Yttrium Tris(N,N'-diisopropylacetamidinate) and Water. <i>Chemistry of Materials</i> , 2005, 17, 4808-4814.	6.7	134
2	Atomic layer deposition of lanthanum aluminum oxide nano-laminates for electrical applications. <i>Applied Physics Letters</i> , 2004, 84, 3957-3959.	3.3	78
3	Highly conformal atomic layer deposition of tantalum oxide using alkylamide precursors. <i>Thin Solid Films</i> , 2003, 443, 1-4.	1.8	64
4	ALD of Scandium Oxide from Scandium Tris(N,N <sup>1</sup> -diisopropylacetamidinate) and Water. <i>Electrochemical and Solid-State Letters</i> , 2006, 9, F45.	2.2	36